

High Stability and Ultralow Threshold Amplified Spontaneous Emission from Formamidinium Lead Halide Perovskite Films

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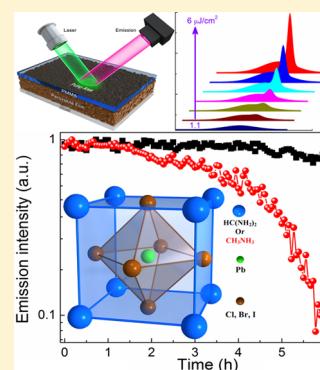
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Supporting Information

ABSTRACT: The opportunity of lasing from organolead halide perovskite materials has recently attracted extensive attention in order to realize electrically driven lasers. So far, for devices with planar structure, most reports focus on $\text{CH}_3\text{NH}_3\text{PbI}_3$ (MAPbI₃) films, which are unstable when in operation due to phase transitions and elemental redistribution. Herein, we demonstrate highly stable amplified spontaneous emission (ASE) with ultralow threshold from formamidinium-based perovskite $\text{CH}(\text{NH}_2)_2\text{PbI}_3$ (FAPbI₃) films. ASE from MABr-stabilized FAPbI₃ films was also achieved, with an ultralow threshold of about $1.6 \mu\text{J}/\text{cm}^2$. More importantly, upon continuous operation under pulsed laser for several hours, the ASE intensity in the MAPbI₃ film decreased to 9% of the initial value, while it was maintained above 90% in the FAPbI₃ film. The low trap density, smooth film morphology, high thermal stability, and the excitonic emission in nature of the FAPbI₃ film are expected to contribute to its low lasing threshold and high stability, demonstrating a strong potential for applications in continuous-wave pumped lasers and electrically driven lasers.



1. INTRODUCTION

In the past few years, hybrid halide perovskites, with the general formula ABX_3 (where A for CH_3NH_3^+ or $\text{HC}(\text{NH}_2)_2^+$ cation; B for Sn^{2+} or Pb^{2+} metal ion; and X for I, Br, Cl), have been at the basis of several breakthroughs in photovoltaic and optoelectronic applications.^{1–6} Employed as light absorbers in solar cells, rapid improvements in the power conversion efficiency (PCE) have been achieved,^{7–9} thanks to a combination of broadband absorption, balanced charge transport properties with long diffusion lengths, and low nonradiative recombination ascribed to their unique defect chemistry.^{1,2,10–12} Current state-of-the-art solar cells based on perovskite materials achieved a certified PCE of 22.1%.¹³ Meanwhile, the demonstration of high photoluminescence (PL) quantum efficiency and optical gain in these hybrid perovskites suggests that these materials should also be effective light emitters for light-emitting diodes and lasers which can be easily tuned across the entire visible spectrum via halogen substitutions.^{3–5,14,15}

Considering the balanced ambipolar charge transport and high gain characteristics of $\text{CH}_3\text{NH}_3\text{PbX}_3$ (MAPbX₃ in the following text), these hybrid perovskite materials show promising prospect for electrically pumped lasers. So far, optically pumped amplified spontaneous emission (ASE) as well as lasing have been demonstrated in a variety of sample morphologies such as polycrystalline thin films,^{15–17} microcavity,^{18,19} nanocrystals,²⁰ nanowires,^{21–23} and distributed

feedback cavity.²⁴ Although the reported thresholds are very promising, major challenges still prevent the use of perovskite-based electrically pumped lasers. One major obstacle for practical applications is the instability that stems from poor thermal stability and high moisture sensitivity of the perovskite film.²⁵ In particular, the thermal stability may impose technical limits for the realization of electrically driven lasers, since the heating caused by the large current injection could potentially cause the degradation of perovskite materials.^{15,26} Moreover, MAPbI₃ undergoes a reversible phase transition between tetragonal and cubic phase at $\sim 330 \text{ K}$,^{27,28} a temperature that might be achieved in an operating optoelectronic device, and the phase transition can modify the emission properties of MAPbI₃. In addition, a lower current density threshold estimated from the optically pumped threshold is desirable, which means that achieving a low-threshold optically pumped laser system is a motivating goal, as it lowers the amount of pump energy necessary to drive the laser. With a long-term view, an electrically pumped laser would be also obviously demonstrated more easily in a low threshold structure. Therefore, materials with high stability and low gain threshold are desirable for the realization of electrically driven lasers.

Received: March 5, 2017

Revised: May 28, 2017

Published: July 3, 2017

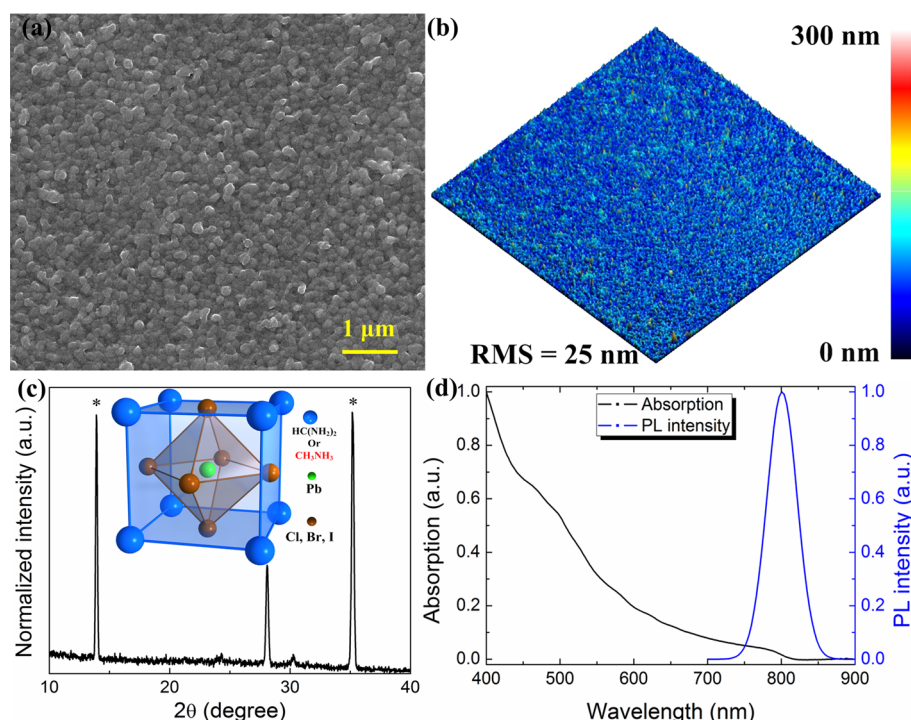


Figure 1. FAPbI₃ film characterization. (a) Top view SEM image of the FAPbI₃ film. (b) 3D AFM image of the FAPbI₃ film. (c) Bragg–Brentano X-ray diffraction pattern for a typical FAPbI₃ film. The main diffraction peaks are labeled with black stars. The inset shows the atomic crystal structure of FAPbI₃ and MAPbI₃. (d) Normalized absorption spectrum and PL spectrum of the FAPbI₃ film.

In this work, we report the ASE in the optically pumped HC(NH₂)₂PbI₃ (shortened as FAPbI₃) and MABr-stabilized FAPbI₃ films, possessing an ultralow threshold of about 1.6 μJ/cm². We further demonstrate tunable perovskite ASE in wider wavelength region from FA-based lead halide perovskite alloys through halogen substitutions. Remarkably, upon pumping with pulsed laser for hours, the FAPbI₃ film displays more durable lasing emission than MAPbI₃. In addition, temperature-dependent PL experiments reveal an exciton binding energy of 29 meV and optical phonon energy of 19 meV, indicating an excitonic emission in nature at room temperature. The improvements in low lasing threshold and high stability in the FAPbI₃ film were expected to stem from its low trap density, smooth film morphology, high thermal stability, and the excitonic emission in nature.

2. EXPERIMENTAL METHODS

Sample Preparation. To prepare the samples, the precleaned glass substrates were cleaned with deionized water and organic solvents and then exposed to a UV–ozone ambient for 5 min. Then, the FAPbI₃ layer was fabricated in N₂ ambient glovebox as follows: Lead iodide (PbI₂, Sigma-Aldrich, 99.999%) and formamidinium iodide (CH(NH₂)₂I, or FAI) were dissolved in anhydrous dimethylformamide (DMF) and 2-propanol, respectively. The PbI₂/DMF precursor solution (369.6 mg/mL) was deposited onto a hot plate at 60 °C with stirring and was maintained at 60 °C before spin coating on substrates to keep its viscosity at an optimized range. Then the PbI₂/DMF solution was spin-coated at 6000 rpm for 60 s onto the substrate and then annealed at 100 °C for 10 min to thoroughly remove the DMF residue. Then 0.4 mL of FAI precursor solution (10.84 mg/mL) was spin-coated at 2000 rpm for 30 s onto the mentioned substrate with PbI₂ (90 nm) all at 60 °C and then annealed at 120 °C for 20 min to form the

perovskite layer. For comparison, the MAPbI₃ film was prepared via the same method by spin-coating the MAI isopropyl alcohol solution (10 mg/mL) onto the mentioned PbI₂ substrate and then annealed at 100 °C for 20 min to form the perovskite layer. Finally, poly(methyl methacrylate) (PMMA) dissolved in the chlorobenzene solution (20 mg/mL) was spin-coated at 1000 rpm for 30 s onto the substrate and then annealed at 100 °C for 10 min to complete device preparation. The PMMA films were spin-coated as encapsulated layer to protect the FAPbI₃ layer from degradation by moisture and oxygen in atmospheric environment. The perovskite film double alloys of (MA,FA)Pb(Br,I)₃ were prepared by reacting PbI₂ film with different ratio FAI and MABr in isopropanol ranging from 1:0 to 0:1.

Sample Characterization. Film thickness of the samples was measured by ellipsometry (SE MF-1000, Korea). The surface of MAPbI₃ layer was investigated by scanning electron microscopy (SEM, Quanta 250, FEI). Surface topography of the MAPbI₃ layer was measured by an atomic force microscope (AFM, NT-MDT, Russia). The crystalline structure of the MAPbI₃ layer on ITO substrate was determined by X-ray diffraction (XRD, D/MAX-2400, Rigaku, Japan). The absorption and PL spectra were obtained by a UV–vis spectrophotometer (HITACHI U-3010, Japan) and a fluorescence spectrometer (Fluoromax-4 spectrofluorometer), respectively. The femtosecond pulses were delivered from the frequency-doubled output of a Ti:sapphire femtosecond laser oscillator. The nanosecond pulses were delivered by a frequency-doubled Nd:YAG laser (Surelite I, Continuum Corp., USA). Face emission spectra were collected by a fiber-optic spectrometer (Ocean Optics SpectraSuite, USB2000).

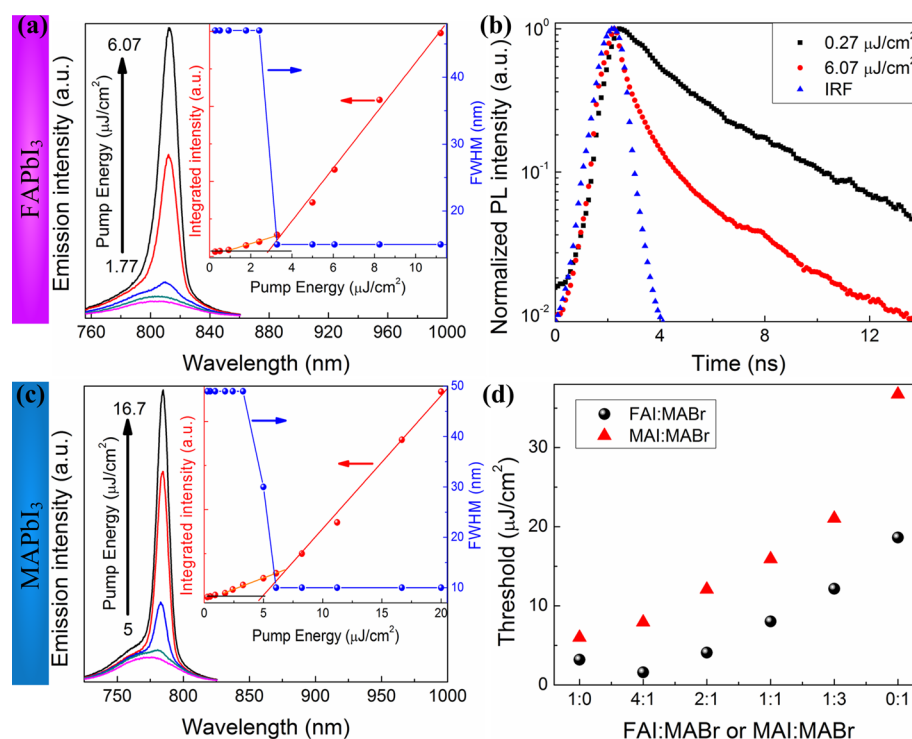


Figure 2. (a) Face emission spectra of FAPbI₃ film pumped by pulsed laser with duration of 150 fs. The insets show the integrated emission intensity and the fwhm of the face emission spectra as a function of pump energy. (b) Time-resolved PL decay kinetics of FAPbI₃ film below (black squares) and above (red circles) ASE threshold. Also shown in blue triangle is the instrument response function. (c) Face emission spectra of MAPbI₃ film pumped by a femtosecond pulsed laser. The insets show the integrated emission intensity and the fwhm of the face emission spectra as a function of pump energy. (d) Wavelength-tunable lasing thresholds achieved by both cation and anion substitutions.

3. RESULTS AND DISCUSSION

To prepare the samples, the hot PbI₂/DMF precursor solution (369.6 mg/mL, 60 °C) was spin-coated onto the preclean glass substrate and then annealed. Then 0.4 mL of FAI isopropyl alcohol solution (10.84 mg/mL) was spin-coated onto the mentioned substrate with PbI₂ (90 nm), all at 60 °C, and then annealed at 120 °C for 20 min in N₂ ambient inside a glovebox. The two stacked precursor layers start forming after deposition and their structure is fully crystallized via thermal annealing to form the perovskite layer through the interdiffusion process.²⁹ For comparison, the MAPbI₃ film was prepared via the same method, by spin-coating the MAI isopropyl alcohol solution (10 mg/mL) onto the mentioned PbI₂ substrate. PMMA films were spin-coated as encapsulating layer to protect the perovskite films from degradation by moisture and oxygen in atmospheric environment (see [Experimental Methods](#)). All measurements were carried out under ambient conditions at room temperature.

A scanning electron micrograph (SEM) of the top surface of the FAPbI₃ film is presented in [Figure 1a](#). The as-formed FAPbI₃ film has full surface coverage on the substrates, with a grain size of about 110–150 nm, which is slightly smaller than the grain size of MAPbI₃ grown in the same conditions ([Figure S1](#), [Supporting Information](#)). The 3D surface topography of the FAPbI₃ film is further evaluated by atomic force microscope (AFM) as shown in [Figure 1b](#). The FAPbI₃ film is relatively smooth compared to other solution-processed films, with the root-mean-square (RMS) of surface roughness about 25 nm over the measured area of 50 μm × 50 μm. [Figure 1c](#) shows the corresponding X-ray diffraction (XRD) of the as-prepared FAPbI₃ film on glass substrate. A set of strong peaks at 13.94°,

28.12°, and 35.21°, assigned to (110), (220), and (312) of the FAPbI₃ crystal, indicates a trigonal crystal structure of halide perovskite with high crystallinity. The normalized optical absorption and PL spectra from the FAPbI₃ film are shown in [Figure 1d](#). The energy gap extracted from the absorption spectra is about 1.55 eV, which is in good agreement with PL spectra exhibiting a SE peak at 801 nm, with the full width at half-maximum (fwhm) about 51 nm. By contrast, the energy gap of MAPbI₃ film is larger, with a PL peak at 765 nm ([Figure S2](#)).

The samples were excited at 400 nm by a frequency-doubled Ti:sapphire femtosecond laser oscillator delivering 150 fs pulses at a 1 kHz repetition rate. Through a pinhole filter and a positive lens, the laser beam formed a 3 mm diameter spot and was irradiated obliquely onto the surface of the samples ([Figure S3](#)). Face emission spectra were collected directly into a fiber optic spectrometer. The measured output emission spectra, input–output intensity, and fwhm of the sample as a function of increasing pump energy are shown in [Figure 2](#). The evolution of light emission spectra from the FAPbI₃ film is illustrated in [Figure 2a](#), showing the transition from the SE to ASE with increasing pump energy. Clearly, as shown in the inset of [Figure 2a](#), there is a visible threshold at about 3 ± 0.5 μJ/cm² in the input–output curve. At low pump energy, only a SE peak is observed. When the pump intensity exceeds the threshold, the spectral narrowing, i.e., ASE, emerges at 812 nm while the fwhm dramatically decreased from ~47 to ~15 nm. The fwhm remains constant upon further increase in the pump energy. ASE can be achieved in the FAPbI₃ film because the spontaneously emitted photons transmitted along the gain media are amplified by stimulated emission. Owing to the stronger self-absorption, ASE does not occur at the SE peak

wavelength 801 nm but 812 nm, where the optical gain and absorption are balanced. Another characteristic and expected feature of ASE, seen in time-resolved experiments (Figure 2b), is the acceleration of radiative recombination due to switching from individual to collective emission. For FAPbI₃ films in this work, at excitation intensities lower than the ASE threshold, typical PL lifetimes of several nanoseconds are observed with nearly single-exponential behavior (Figure 2b, black squares). Well above the ASE threshold, an ASE lifetime of few hundred picoseconds, limited by instrument resolution, can be roughly estimated from a biexponential fit, assuming competing ASE and PL processes (Figure 2b, red circles). In addition, the first intersection shown in the inset of Figure 2a represents the pump energy needed to fill all the traps (i.e., the threshold trap pump energy P_{th}^{Trap}). $P_{th}^{Trap} \sim 1 \mu\text{J}/\text{cm}^2$ is shown in the input–output curve, corresponding to a trap state density of about 10^{17} cm^{-3} . By contrast, the MAPbI₃ film possesses a higher threshold—about $6 \mu\text{J}/\text{cm}^2$ —than the FAPbI₃ film, which indicates a higher trap state density, about $2.5 \times 10^{17} \text{ cm}^{-3}$, as clearly shown in Figure 2c. In addition, we grow perovskite film double alloys of (MA,FA)Pb(Br,I)₃ by reacting PbI₂ film with a mixed solution of FAI and MABr in isopropanol (Figure S4) to achieve wavelength-tunable lasing from 820 to 615 nm (Figure S5). The thresholds increase with the increasing proportion of MABr, ranging from about 1.6 to $37 \mu\text{J}/\text{cm}^2$, as shown in Figure 2d. It is worth to mention that a threshold as low as $1.6 \mu\text{J}/\text{cm}^2$ is achieved in the perovskite film for FAI:MABr = 4:1, which probably is enabled by the smooth film morphology and the low trap state density (Figure S6). Furthermore, appropriate proportion of MABr and FAI in the PbI₂ skeleton could improve the phase stability of FAPbI₃,^{9,30} which is also beneficial to the improved luminescence properties of the MABr-stabilized FAPbI₃ films.

A quasi-continuous wave regime of excitation can be observed with pumping pulses of longer duration than the ASE lifetime, though at the expense of higher overall pumping energy to maintain the same instant excitation intensity over the whole pulse duration. In order to further investigate the potential for “quasi-continuous wave” regime of excitation, face emission spectra from FAPbI₃ film pumped by a nanosecond pulsed laser (532 nm, 5.5 ns, 10 Hz) were obtained with pumping pulses much larger than the ASE lifetime of FAPbI₃ (about a few hundred picoseconds). The evolution of light emission spectra is illustrated in Figure 3a, showing a threshold at about $19.5 \mu\text{J}/\text{cm}^2$, which validates the potential for employing this material for the realization of continuous-wave (CW) pumped lasers.

For implementing perovskite lasing into optoelectronic devices, the photostability of the emission needs to be assessed. We tested the lasing stability of FAPbI₃ and MAPbI₃ by pumping them with a 532 nm pulsed laser (5 ns, 10 Hz) at power density above the threshold for several hours. In addition, the photostability of the FAPbI₃ and MAPbI₃ film was assessed by monitoring the ASE intensity as a function of time under continuous laser pulse $128 \mu\text{J}/\text{cm}^2$ for 6 h at room temperature, as shown in Figure 3b. Upon continuously pumping, the ASE intensity in the MAPbI₃ film decreased to 9% of the initial value, while it was only mostly retained (90% of the starting value) in the FAPbI₃ film. The lack of decay in the emission intensity confirmed the excellent optical stability of the FAPbI₃ gain media, which excluded the influence of material degradation or pump energy attenuation on the above-mentioned emission intensity decrease with the continuous

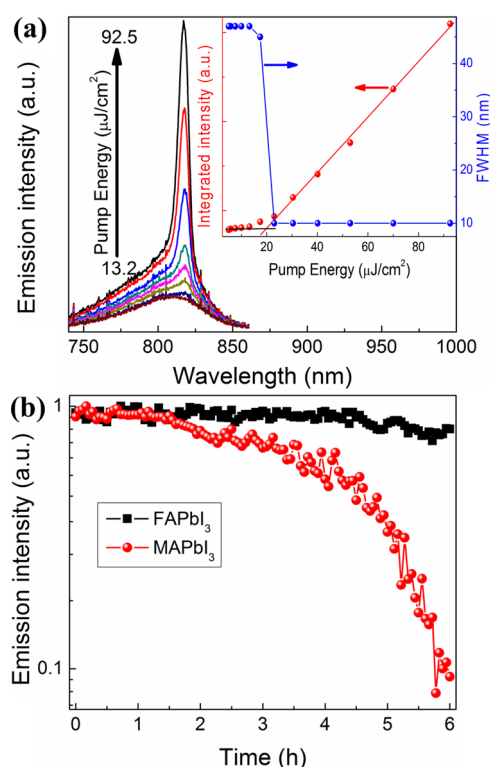


Figure 3. (a) Face emission spectra of FAPbI₃ layer pumped by ns pulsed laser. The insets show the integrated emission intensity and the fwhm of the face emission spectra as a function of pump energy. (b) ASE intensity as a function of time under continuous laser pulse at power density above the threshold at room temperature.

laser pulse. We deduced that the improved photostability of FAPbI₃ film over MAPbI₃ film may derive from two important factors. First, FAPbI₃ film is relatively less susceptible to the generated heat induced by sustained laser illumination due to better thermal stability than MAPbI₃.²⁷ Second, the larger FA cation size and the enhanced interaction between FA cations and iodine ions may abate the light-induced ion migration in FAPbI₃ film.³¹ We should emphasize that the deeper insight into the excellent optical stability of the FAPbI₃ film demands further structural and optical investigations, which is beyond the scope of this paper.

To investigate the intrinsic optical properties of different crystalline phase structures of the perovskites films, temperature-dependent PL measurements from 80 to 340 K were carried out, and the data are summarized in Figure 4. The optical excitation is set at low pump energy ($0.5 \mu\text{J}/\text{cm}^2$) in order to thoroughly comprehend the phase transition in the perovskites in a broad temperature range. As shown in Figure 4a, the temperature-dependent PL emission intensity of the fabricated FAPbI₃ film gradually decreases with increase of temperature, indicating thermal quenching of photoinduced charge generation. In a sequence of cooling process from 340 to 80 K, a sharp peak occurs at 140 K, and the corresponding PL emission spectrum is centered at 838 nm. All the PL emission spectra show a blue-shift tendency on their central wavelengths except an obvious variation of the spectral characteristics in a range of temperatures from 120 to 160 K. Such a temperature range of the PL spectral behavior change of FAPbI₃ during the temperature-increasing process may refer to a structural phase transition which occurs from hexagonal to trigonal crystalline structure, as described by Kanatzidis et al.,²⁷ while a recent

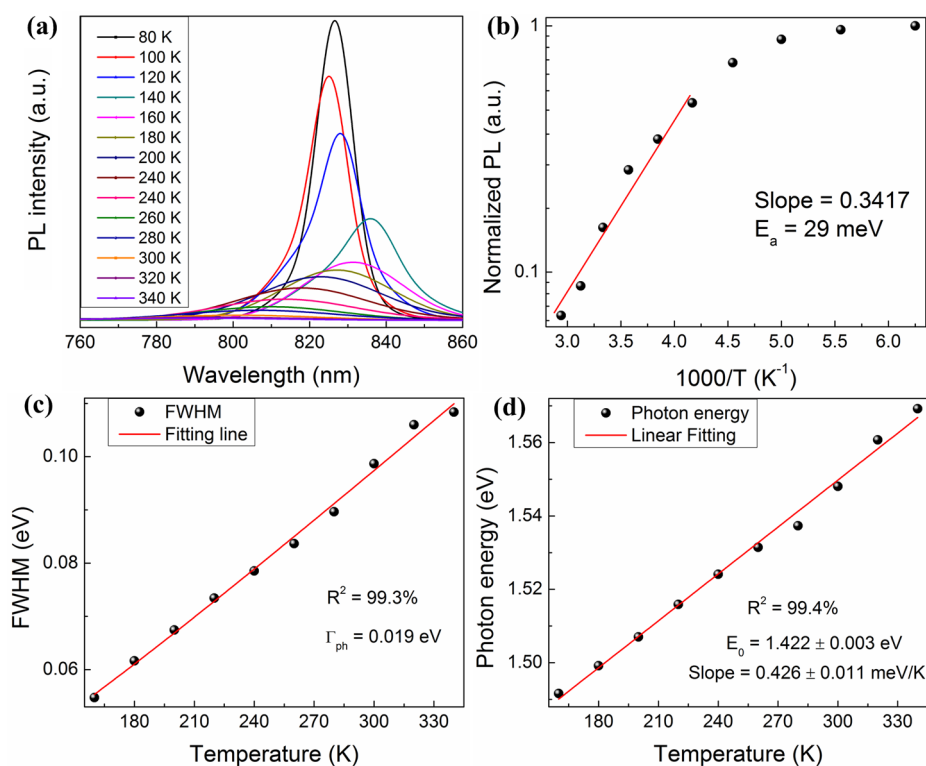


Figure 4. Temperature-dependent PL analysis results for the FAPbI₃ film. (a) Temperature-dependent PL spectra taken from 80 to 340 K. (b) Arrhenius plots of the temperature dependence of the integrated PL intensity. The data have been normalized to the intensity at 160 K. The solid lines are linear regressions at high temperatures to extract the values of the activation energies E_a . (c) The spectra fwhm vs temperature for FAPbI₃ film. Only the region from 160 to 340 K can be fitted with eq 1 since the material undergoes a phase transition at 160 K. The analysis yields values of 0.019 eV for Γ_{ph} . (d) Temperature-dependent data of the emission peak energy above 160 K. The solid lines are the linear fitting line.

report also revealed a first-order phase transition from tetragonal β -phase to tetragonal γ -phase at around 140 K.³² Similar evolution of the PL emission spectra in MAPbI₃ film with the cooling process from 340 to 80 K is observed, which also show a structural phase transition in a range of temperatures from 120 to 160 K (Figure S7). The structural phase transition from orthorhombic to tetragonal crystalline structures at about 160 K in MAPbI₃ film has been observed in some other studies.^{33–35} This phase transition in temperature-dependent experiments derives from a tilting of the PbI₆-octahedra out of the *ab*-plane.³⁵ Similar structural phase transition was also observed in other organic–inorganic lead bromide perovskite microstructures.³⁶

As mentioned above, the temperature-dependent PL experiments were performed at very low excitation density under femtosecond laser pulse, which corresponds to the onset of the appearance of the first excited state. The temperature quenching of the PL intensity is due to the thermally activated depopulation of the excitonic level and/or to the activation of nonradiative recombination centers. Since PL intensities are inversely proportional to nonradiative lifetimes $\tau \propto \exp(E_a/kT)$, the activation energies E_a of the processes involved can therefore be determined from the slope of an Arrhenius plot of the integrated PL intensity for the FAPbI₃ film as shown in Figure 4b. The shape of these curves is typical of the temperature dependence for semiconductors.^{37,38} The regime of strong thermal quenching at high temperatures tends toward a straight line, characteristic of an exponential quenching $\propto \exp(E_a/kT)$. We can deduce the activation energy E_a for the FAPbI₃ film by measuring the slope. The slope of the fitting

line is about 0.3417, corresponding to the activation energy E_a for about 29 meV, which is slightly smaller than the value of E_a for the MAPbI₃ film (Figure S8). The temperature quenching of the PL intensity is due to the exciton thermal dissociation,³³ the activation energy E_a therefore is closely matched to the exciton binding energy, which is about 29 meV for the FAPbI₃ film. This value is higher than that obtained from the temperature-dependent PL analysis in recent reports, which probably stems from the differences in the film parameters such as grains dimension distribution and orientation.^{6,39} The exciton binding energies for the FAPbI₃ and MAPbI₃ film are both comparable to the thermal kinetic energy of ~ 26 meV at room temperature, declaring the coexistence of free carriers and excitons. The fundamental nature of excited state species in these FAPbI₃ and MAPbI₃ film is more like free carriers under low excitation regime but dominant by geminate recombination at high excitation regime.⁴⁰

In addition, the line width of PL spectra in FAPbI₃ gradually broaden from 160 to 340 K as clearly shown in Figure 4a, which is attributed to electron–phonon coupling.^{39,41} To establish qualitatively which electron–phonon scattering mechanisms dominate in FAPbI₃, the line broadening of the band-edge PL emission for both compounds was measured as a function of temperature to determine the phonon energy, Γ_{ph} . The temperature dependence of peak width for excitonic peaks was analyzed using Toyozawa's equation:^{42,43}

$$\Gamma(T) = \frac{A}{\exp\left(\frac{\Gamma_{ph}}{k_B T}\right) - 1} + C \quad (1)$$

where $\Gamma(T)$ is the fwhm and C is a constant line width at low temperatures due to the absence of phonon broadening. From the analysis of spectral data shown in Figure 4c using eq 1, a phonon energy Γ_{ph} of about 0.019 eV was calculated for FAPbI₃ and 0.026 eV for MAPbI₃ (Figure S9), which is close to the value reported in other study.⁴¹ Furthermore, as shown in Figure 4a, from 160 to 340 K, the PL spectra peaks in FAPbI₃ all continually red-shift because the band gap decreases with increasing temperature.³³ The decrease tends to vary linearly with temperature above phase transition temperature. The energy of the PL peak changes almost linearly with the temperature as shown in Figure 4d. The continuous blue-shift for temperatures higher than 160 K can be described by a temperature coefficient $\alpha = \partial E/\partial T = 0.426$ meV/K. This counterintuitive blue-shift was also observed in lead/copper chalcogenide semiconductors like PbS(Se/Te) and CuCl(Br/I).⁴⁴

To further identify the underlying recombination mechanisms in these hybrid perovskites, the dependence of photoluminescence on pump power was studied. The low-temperature PL from compound semiconductors with reasonably good crystalline quality is dominated by near-band-edge photoluminescence (NBEPL). It has been stated that the underlying recombination process can be identified from the behavior of the PL intensity as the excitation power is varied. As a general result, it has been found that the luminescence intensity I of the NBEPL emission lines is proportional to L^k , where L is the power of the exciting laser radiation and $1 < k < 2$ for exciton-like transition and $k < 1$ for free-to-bound and donor–acceptor pair transitions.^{38,43,45} To investigate this further, we made a more comprehensive study of the excitation density dependence of the PL intensity at 80 and 293 K. As shown in Figure 5a, at the excitation density ranging from 10^{16} to 2×10^{18} cm⁻³, the straight lines are linear regressions for FAPbI₃ film. A purely linear behavior is characterized by a slope of about 0.96 at 80 K. However, the behavior is then superlinear with the slope increasing to 1.21 at 293 K. For MAPbI₃, $k = 1.2$ at 80 K and $k = 1.51$ at 293 K shown in Figure 5b. The value of $k = 1.21$ at room temperature for FAPbI₃ is expected for free exciton transitions since their intensity is directly proportional to the total number of excitons, which is proportional to the excitation densities. Thus, it is concluded that the power-dependent PL measurements indicate that the PL recombination mechanism for FAPbI₃ is excitonic in nature at intermediate excitation densities at room temperature, coinciding with the above-mentioned results, which is perceived as one of the reasons that FAPbI₃ possesses excellent lasing properties.

4. CONCLUSIONS

In summary, the ASE emission in organolead halide perovskite FAPbI₃ film has been investigated. Compared to MAPbI₃, FAPbI₃ possesses lower threshold and higher stability derived from its low trap density and high thermal stability, which makes it more suitable for the CW pumped lasers or electrically driven lasers. We further demonstrate tunable perovskite lasing in wider wavelength region from FA-based lead halide perovskite alloys through halogen substitutions. In addition, temperature-dependent PL experiments revealed an exciton binding energy of 29 meV and optical phonon energy of 19 meV, indicating an excitonic emission in nature at room temperature. Our results provide useful insights into the optical

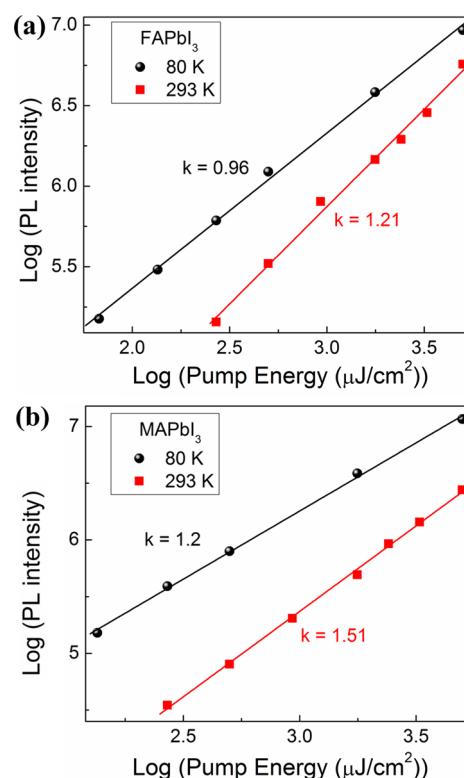


Figure 5. A log–log plot of the pump energy versus the integrated PL intensity at different temperatures for (a) FAPbI₃ film and (b) MAPbI₃ film. The solid lines are linear regressions.

properties of such important hybrid perovskites, promoting their future applications in optoelectronic devices.

■ ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.jpcc.7b02101.

SEM, Abs, and PL spectrum of MAPbI₃, schematic configuration, SEM of (MA,FA)Pb(Br,I)₃, wavelength-tunable SE and ASE, spectra of the MABr-stabilized FAPbI₃ film, temperature-dependent PL spectra, activation energy and phonon energy for MAPbI₃ (PDF)

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Author Contributions

F.Y. and Z.W. contributed equally to the work.

Notes

The authors declare no competing financial interest.

■ ACKNOWLEDGMENTS

This work was financially supported by Basic Research Program of China (2013CB328705), National Natural Science Foundation of China (Grant No. 61275034), and Ph.D. Programs Foundation of Ministry of Education of China (Grant No. 20130201110065). The SEM work was done at International Center for Dielectric Research (ICDR), Xi'an Jiaotong

University, Xi'an, China; the authors also thank Ms. Dai for her help in using SEM.

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